

	Application No.	Applicant(s)
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Notice of Allowability	10/627,563	LEWRY ET AL.
Notice of Allowability	Examiner	Art Unit
	Shih-Chao Chen	2821
The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communication GHTS. This application is subject to	plication. If not included now in the mailed in due course. THIS
1. This communication is responsive to the amendment filed of	<u>on June 7, 2005</u> .	
2. The allowed claim(s) is/are <u>1-27</u> .		
3. $\boxtimes$ The drawings filed on <u>07 March 2005</u> are accepted by the	Examiner.	
<ul> <li>4. Acknowledgment is made of a claim for foreign priority una) All b) Some* c) None of the: <ol> <li>Certified copies of the priority documents have</li> <li>Certified copies of the priority documents have</li> <li>Copies of the certified copies of the priority documents have</li> <li>Copies of the certified copies of the priority documents have</li> <li>Copies of the certified copies of the priority documents have</li> <li>Copies of the certified copies of the priority documents have</li> <li>Certified copies of the priority documents have</li> <li>The priority documents have</li> <li>The priority documents have</li> <li>Certified copies of the priority documents have</li> <li>The priority docum</li></ol></li></ul>	been received. been received in Application No cuments have been received in this of this communication to file a reply	national stage application from the
5. A SUBSTITUTE OATH OR DECLARATION must be subminformal PATENT APPLICATION (PTO-152) which give	es reason(s) why the oath or declara	
6. CORRECTED DRAWINGS (as "replacement sheets") mus		240
(a) ☐ including changes required by the Notice of Draftspers	•	-948) attached
1) hereto or 2) to Paper No./Mail Date		NET Al E
<ul><li>(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date</li></ul>	s Amendment / Comment or in the C	office action of
Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in ti		
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT		
Attachment(s)  1. Notice of References Cited (PTO-892)	5. Notice of Informal F	Patent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary	(PTO-413),
Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date	Paper No./Mail Da 08), 7. ☐ Examiner's Amendr	te ment/Comment
4.   Examiner's Comment Regarding Requirement for Deposit	8. X Examiner's Stateme	ent of Reasons for Allowance
of Biological Material	9.  Other	
		Shik-Wwo Chen Shih-Chao Chen Primary Examiner

Application/Control Number: 10/627,563

Art Unit: 2821

## **DETAILED ACTION**

## Allowable Subject Matter

- 1. Claims 1-27 are allowed (Claims 28 are canceled by Applicant).
- 2. The following is an examiner's statement of reasons for allowance: See Office Action mailed on May 3, 2005.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Correspondence

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shih-Chao Chen whose telephone number is (571) 272-1819. The examiner can normally be reached on Monday-Friday from 7 AM to 4:30 PM, First Fri. off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don Wong can be reached on (571) 272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Shih-Chao Chen Primary Examiner Art Unit 2821 SHIH-CHAO CHEN PRIMARY EXAMINER

SXC June 13, 2005